

Application No.	Applicant(s)	
10/699,933	SUZUKI, MASAYUKI	
Examiner	Art Unit	
D. Putledge	2851	

SEARCHED				
Class	Subclass	Date	Examiner	
355	53, 67-71	6/12/2004	DR	
359	364,365	6/12/2004	DR	
359	857-859	6/12/2004	DR	
250	492.1,	6/12/2004	DR	
250	492.2	6/12/2004	DR	
	,			
			,	

INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	
355	53,67-71	6/13/2004	DR	
359	364,365	6/13/2004	DR	
359	857-859	6/13/2004	DR	
250 492.1, 492.2		6/13/2004	DR	

SEARCH NOTES (INCLUDING SEARCH STRATEGY)				
	DATE	EXMR		
exposure, projection, lithograph\$4, photolithograph\$4, catoptric, optical, microlithograph\$4, 6, six, mirror, reflection	6/12/2004	DR		
sixth, concave, convex, mask, reticle, wafer, substrate, diameter, nm, 1500, radius, curvature, slope, flux, maximum	6/12/2004	DR		
incident, angle	6/12/2004	DR		